Search Notes

| Application/Control No. | Applicant(s)/Patent under Reexamination | |
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| 10/808,793 | HILL ET AL. | |
| Examiner | - Art Unit | |
| Victor V. Yevsikov | 2891 | |

| | SEARCHED | | | | | |
|----------|-------------------------------|-----------|----------|--|--|--|
| Class | Subclass | Date | Examiner | | | |
| 438 | 257,258 241,275 689,286 | 3/25/2006 | VY | | | |
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| INT | INTERFERENCE SEARCHED | | | | |
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| SEARCH NOTES (INCLUDING SEARCH STRATEGY) | | | | |
|---|-----------|------|--|--|
| | DATE | EXMR | | |
| EAST flash memory gate stack applied materials advanced patterning film hard mask | 3/25/2006 | VY | | |
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